

PATENT  
3430-0131P



IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:	HWANG, Kwang-Jo	Conf.:	5562
Appl. No.:	09/648,111	Group:	2815
Filed:	August 25, 2000	Examiner:	Brock II, P.
For:	METHOD OF PATTERNING A METAL LAYER IN A SEMICONDUCTOR DEVICE		

# LARGE ENTITY TRANSMITTAL FORM

Assistant Commissioner for Patents  
Washington, DC 20231

August 27, 2002

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Sir:

Transmitted herewith is an amendment in the above-identified application.

- ☐ The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.
- ☐ The enclosed document is being transmitted via facsimile.

The fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR		PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	30	-	29	=	1	\$18	\$18.00
INDEPENDENT	3	-	3	=	0	\$84	\$0.00
<input type="checkbox"/> FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM						\$280	\$0.00
						TOTAL	\$18.00

- ☐ Petition for ( ) month(s) extension of time pursuant to 37 C.F.R. §§ 1.17 and 1.136(a). \$0.00 for the extension of time.
- ☐ No fee is required.
- ☒ Check(s) in the amount of \$18.00 is(are) enclosed.
- ☐ Please charge Deposit Account No. 02-2448 in the amount of \$0.00. This form is submitted in triplicate.


If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By 

Joseph A. Kolasch, #22,463

  
JAK/PLS/asc  
3430-0131P

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ATTACHMENT

(Rev. 09/27/01)



PATENT  
3430-0131P

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT(S): HWANG, Kwang-Jo CONF.: 5562  
SERIAL NO.: 09/648,111 GROUP: 2815  
FILED: August 25, 2000 EXAMINER: Brock II, P.  
FOR: METHOD OF PATTERNING A METAL LAYER IN A  
SEMICONDUCTOR DEVICE

**AMENDMENT**

Assistant Commissioner for Patents  
Washington, D.C. 20231

August 7, 2002

Dear Sir:

In response to the non-final Office Action dated May 7, 2002, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

IN THE CLAIMS:

Please amend the claims as follows:

1. (Twice Amended) A method of manufacturing a liquid crystal display device, comprising:
- forming a switching element on a substrate;
  - forming a passivation layer over the substrate;
  - depositing a metal layer on the passivation layer;

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